



1449 (Modified)

Information Disclosure  
Statement By Applicant  
(Use Several Sheets if Necessary)

Atty Docket No.  
NOVLP085/NVLS-2875

Application No.:  
10/785,235

Applicant:

Wang et al.

Filing Date

February 23, 2004

Group

2812

#### U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
	A1	6,797,643 B2	09.2004	Rocha-Alvarez et al.			
	A2	6,815,373 B2	11.2004	Singh et al.			
	A3	6,914,014 B2	07.2005	Li et al.			
	A4	2004/0101633 A1	05.2004	Zheng et al.			
	A5	6,258,735 B1	07.2001	Xia et al.			
	A6	6,610,362 B1	08.2003	Towle, Steven N.			
	A7	6,632,478 B2	10.2003	Gaillard et al.			
	A8	2004/0096593 A1	05.2004	Lukas et al.			
	A9	2004/0161532 A1	08.2004	Kloster et al.			
	A10	2004/0170760 A1	09.2004	Meagley et al.			
	A11	2005/0064698 A1	03.2005	Chang et al.			
	A12	6,715,498 B1	04.2004	Humayun et al.			
	A13	5,849,640	12.1998	Hsia et al.			
	A14	6,573,030 B1	06.03.03	Fairbairn et al.			
	A15	2004/0096586 A1	05.2004	Schulberg et al.			
	A16	2003/0198895 A1	10.2003	Toma et al.			
	A17	6,846,380 B2	01.2005	Dickinson et al.			

#### Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation
							Yes No

#### Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
	C1	U.S. Office Action mailed December 27, 2005, from U.S Application No. 10/789,103 [Atty Dkt No. NOVLP094/NVLS-002919].
	C2	U.S. Office Action mailed December 23, 2005, from U.S Application No. 10/800,409 [Atty Dkt No. NOVLP098/NVLS-002907].
	C3	U.S. Office Action mailed February 7, 2006, from U.S Application No. 10/672,305 [Atty Dkt No. NOVLP069/NVLS-000821].
	C4	U.S. Office Action mailed December 20, 2005, from U.S Application No. 10/672,311 [Atty Dkt No. NOVLP075/NVLS-000820].
Examiner		Date Considered <i>5/12/06</i>

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

<b>Form 1449 (Modified)</b>	Atty Docket No. NOVL085/NVLS-2875	Application No.: 10/785,235
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## **U.S. Patent Documents**

**Foreign Patent or Published Foreign Patent Application**

#### **Other Documents**

Other Documents		
Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
	C5	U.S. Office Action mailed December 20, 2005, from U.S Application No. 10/849,568 [Atty Dkt No. NOVLP083/NVLS-2867].
	C6	Subramonium et al., "Pulsed PECVD Method for Modulating Hydrogen Content in Hard Mask", U.S. Application No. 11/318,269, filed December 23, 2005 (Atty Dkt: NOVLP144/NVLS-3102)
	C7	U.S. Office Action mailed February 28, 2006, from U.S Application No. 10/404,693 [Atty Dkt No. NOVLP064/NVLS-794].
	C9	U.S. Office Action mailed March 29, 2006, from U.S Application No. 10/800,377 [Atty Dkt No. NOVLP089/NVLS-002886].
Examiner 	Date Considered	5/12/06

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.